

Technical Data Sheet Topadd[®] TP-20

Description

TP-20 is a acrylic processing aid based on medium-low molecular weight . it has good flowability and dispersion and can efficiently improve surface glossiness of PVC final products. it is used to produce all kinds of PVC products, especially for PVC transparent proudcs with high clarity owing to its faster fusion time and good flowability.

Advantage

- •Excellent dispersion and good clarity
- •Superior fusion-promotion property
- •More homogenous melt and good compatibility with PVC resin.
- •High output rate
- •Good surface-gloss of PVC finished products

Specification	Unit	Test standard	TP-20
Appearance			White powder
Bulk density	g/cm3	GB/T 1636-2008	0.45±0.10
Sieve residue (40 mesh)	%	GB/T 2916	≤2.0
Volatile content	%	ASTM D5668	≤1.2
Intrinsic visosity (η)		GB/T 16321.1-2008	2.5-3.2
Molecular weight (million)	million		0.8-1.5

Similar products

Rohm & Hass : K-120/120ND Kaneka : PA-20 LG CHEM : PA-912 MITSUBISHI RAYON : P-551A BAERLOCHER : 3F

Package and Storage

25kg PP woven bag with PE liner or 20kg paper bag with PE linerShould be stored in dry and ventilated storeroom. This product is non-dangerous.For other operations, please refer to SDS instructions provided by the manufacturer.www.novistagroup.cominfo@novistagroup.com+86-536-8206760

The information presented herein is believed to be accurate and reliable, but is presented without guarantee or responsibility on the part of Novista Group and its subsidiaries. It is the responsibility of the user to comply with all applicable laws and regulations and to provide for a safe workplace. The user should consider any health or safety hazards or information contained herein only as a guide, and should take those precautions which are necessary or prudent to instruct employees and to develop work practice procedures in order to promote a safe work environment. Further, nothing contained herein shall be taken as an inducement or recommendation to manufacture or use any of the herein materials or processes in violation of existing or future patent.